

Ab initio shallow acceptor levels in gallium nitride

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Impurity levels and formation energies of acceptors in wurtzite GaN are predicted ab initio. Be_{Ga} is found to be the shallow (thermal ionization energy ~ 0.06 eV); Mg_{Ga} and Zn_{Ga} are mid-deep acceptors (0.23 eV and 0.33 eV respectively); Ca_{Ga} and Cd_{Ga} are deep acceptors (~ 0.65 eV); Si_N is a midgap trap with high formation energy; finally, contrary to recent claims, C_N is a deep acceptor (0.65 eV). Interstitials and heteroantisites are energetically not competitive with substitutional incorporation.

1. Introduction

Gallium nitride has recently emerged as a serious candidate for the fabrication of green to violet light emitting devices. Blue to yellow-green LED's^{1,2} and, most recently, a GaN-based blue laser have been demonstrated.² A basic problem that needs to be solved is that of reproducible and efficient *p*-type doping of GaN. Mg was successfully employed as *p*-dopant for device applications³ only after elaborate post-growth treatments, and despite its large (~ 0.25 eV) ionization energy. The relevant basic mechanisms are still under scrutiny.⁴

There is thus an obvious interest in shallower acceptors for GaN, and first-principle theoretical investigations can reliably indicate suitable candidates to this end. In this paper we present a preliminary account of ab initio studies on impurities from Groups IIA, IIB, and IV in wurtzite GaN. Our main results are: Be_{Ga}, with a thermal level at 0.06 eV above the valence band, is the shallowest acceptor reported so far in GaN; Mg_{Ga} and Zn_{Ga} are found to be mid-deep acceptors (0.23 eV and 0.33 eV respectively) in good agreement with experiments; C_N, Ca_{Ga}, and Cd_{Ga} are deep acceptors (around 0.65 eV); Si_N is a midgap trap (1.97 eV) with high formation energy. Importantly, preliminary results on interstitials and heteroantisites indicate that these are energetically not competitive with substitutional incorporation.

2. Method

The calculation of acceptor levels and formation energies is non-trivial, especially in a computationally demanding system such as GaN. We calculate local-density-functional total energies and forces with a conjugate-gradient minimization scheme,⁵ plane-waves, and ultrasoft pseudopotentials.⁶ By the latter, we describe accurately all “difficult” electronic states (such as Ga and Zn *3d*, N *2p*, Be *2s*, Cd *4d*, Mg and Ca semicore *s* and *p*, etc.) with a cutoff of 25 Ryd. The defects are simulated by single impurities in 32-atom wurtzite GaN supercells. Full geometry optimization is performed in all cases, using a newly developed method (details given elsewhere). The impurity formation energy in the charge state Q (Q is the number of electrons

transferred *from* the defect *to* a reservoir of chemical potential μ_e) is given by

$$E_f(Q) = E^{\text{tot}}(Q) - n^{\text{Ga}}\mu^{\text{Ga}} - n^{\text{N}}\mu^{\text{N}} - n^{\text{X}}\mu^{\text{X}} + Q(\mu_e + E_v), \quad (1)$$

where $E^{\text{tot}}(Q)$ is the defected supercell total energy in the specific charge state, μ_e the electron chemical potential, E_v the top valence band energy, n^{Ga} , n^{N} , and n^{X} are the number of Ga, N, and X atoms, and μ^{Ga} , μ^{N} , and μ^{X} their chemical potentials. These potentials must satisfy the equilibrium conditions with GaN and with appropriate solubility-limiting X-N or X-Ga compounds (whose properties are also calculated *ab initio*). To study the case of maximum impurity solubility, we fix μ_{X} at the maximum value compatible with the solubility limit; in this case a single free potential remains (e.g. μ_{N}), which is determined by the imposed growth conditions.

The thermal ionization level $\epsilon(0/-)$ of a single acceptor is by definition the formation energy difference of the two charge states $Q=0$ and $Q=-1$ at $\mu_e=0$, or otherwise stated the electron chemical potential value at which the negatively charged state becomes favored over the neutral one. This effectively corresponds to the capture of an electron in the center with concurrent geometric relaxation. The optical level, accessible in luminescence experiments, is obtained summing the calculated Franck-Condon shift to the thermal energy. To refer the energies of different charge states to the same zero, we align the supercell local potentials in appropriate bulk-like regions. By bulk-like region we mean one where the macroscopic average⁷ of the local potential is flat and unaffected by the impurity. Such regions are chosen on the wurtzite *c*-axis, along which the impurity state decays faster (see below), and the inter-acceptor distance is maximal (~ 20 bohr). Fig. 1 exemplifies the procedure for Zn: a plateau appears halfway between the impurities (placed at 0 and 1), and it is there that we pick the potential values for the alignment.

Ideally, one should reach bulk-like regions with the *same* potential value no matter in which direction one moves away from the impurity; an upper bound of the alignment uncertainty is thus the difference of the constant values along e.g. the *a* and *c* axis. This directional deviation is essentially all of our “formal” error bar in the calculated levels, as our calculations are otherwise well converged in terms of technical ingredients. It amounts to ~ 0.05 eV for Zn (Fig. 1), and is generally of order 0.1 to 0.2 eV at worst.

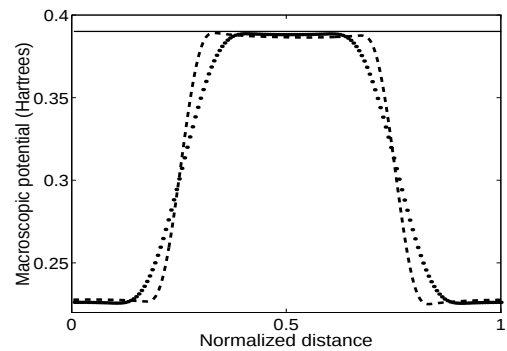


Fig. 1: Local potential macroscopic averages on *c*-axis for bulk GaN (solid) and Zn^0 (dashed), and on *a*-axis for Zn^0 (dotted).

3. Results and Discussion

In Table 1, we summarize the results for the acceptors of groups II-A, II-B, and IV. A new candidate *p*-dopant emerges: Be_{Ga} , with a thermal level at $E_v + 0.06$

eV. Mg and Zn are progressively deeper (0.23 eV and 0.33 eV), while all others are definitely deep. In n -type conditions ($\mu_e \sim E_{\text{gap}} \simeq 3.4$ eV) the formation energies of all acceptors in their negative charge state (except Si_N) are low or negative, which makes them efficient donor compensators. While in p -type and Ga-rich conditions compensation by nitrogen vacancy donors is known to be a problem, from calculations

Table 1. Acceptors in wurtzite GaN. Formation energies E_f of the neutral charge state in N-rich conditions, thermal impurity levels, relaxation contribution E_r , change in distance to neighbors in the a -plane (Δd_a) and along the c -axis (Δd_c) in percentage of the ideal bond length, solubility limits and their formation enthalpy. All energies are in eV.

Defect	E_f	$\epsilon(0/-)$	E_r	Δd_a	Δd_c	limit	$-\Delta H_f$
Be_{Ga}	2.29	0.06	0.40	-5.5	-8.4	Be_3N_2	6.70
Mg_{Ga}	1.40	0.23	0.21	+3.2	+3.2	Mg_3N_2	4.96
Zn_{Ga}	1.21	0.33	0.03	+1.1	-0.5	Zn_3N_2	1.28
Ca_{Ga}	2.15	0.62	1.87	+10.0	+12.7	Ca_3N_2	4.91
Cd_{Ga}	1.60	0.65	1.40	+9.2	+8.8	h-Cd	
C_N	4.24	0.65	0.04	+0.5	-0.6	d-C	
Si_N	5.49	1.97	3.36	+12.0	+11.8	d-Si	
V_N^+	2.32		0.07	0.0	+1.2	w-GaN	1.65

of impurity concentrations accounting for the formation of singly-positive nitrogen vacancies (formation energies: 2.32 eV (N-rich) and 0.67 eV (Ga-rich) at $\mu_e = 0$) and for overall neutrality,⁸ we find that acceptor-vacancy compensation in p -type conditions is essentially suppressed for all species in N-rich conditions. In p -type conditions, formation energies are low for Zn and Mg, somewhat higher for Be, high for C_N , very high for Si_N . The carrier concentration at room temperature for the shallowest acceptor (Be) in N-rich conditions and at MOCVD growth temperatures, ranges from $\sim 3 \times 10^{16} \text{ cm}^{-3}$ to $\sim 4 \times 10^{18} \text{ cm}^{-3}$ for a formation entropy of 0 to 10 k_B . The incorporation mechanism suggested⁴ for Mg may be helpful also in the case of Be: the calculated formation energy of the Be-H complex (limits: H_2 and Be_3N_2) is as low as 0.32 (0.87) eV/pair in N-rich (Ga-rich) conditions. The concentration of Be thus incorporated would grow by 3 orders of magnitude. Of course H is also incorporated, and must be detached from the complex to activate the acceptor: this requires about 1.5 eV for the Be-H complex, so that LEEBI or thermal annealing may be needed.

Contrary to recent claims⁹ on the C_N acceptor being shallow (~ 0.2 eV), we find it to be deep, with a thermal ionization energy of 0.65 eV. Due to its high formation energy in p -type conditions, any appreciable role of C_N as a shallow dopant, and in p -type conditions, is to be ruled out. On the other hand its formation energy drops to near zero in n -type conditions, so it may be present in high concentrations in n -GaN. The optically active level is 0.8 eV above the valence band.

The electronic structure of the acceptors is unusual in several respects. *First*, the

impurity states of the Ga-substituting species (including the mid-deep and shallow ones) are largely localized on the first-neighbor N shell. *Second*, the impurity states are of N p_{xy} -like character. This is a reminder of the impurity state's origin from the Γ_6 top valence band doublet; as such, it is of course peculiar of wurtzite GaN. The state is generally localized in the a -plane, and decays rapidly along the c -axis. We display it for Mg in Fig. 2. The unusual shape of the impurity state affects the properties of H-acceptor complexes: e.g., H's preferential binding at the N-antibonding site in the a -plane rather than along the c -axis, correlates with the a -plane localization of the state accepting the extra electron. *Third*, in all cases, we find a sizable polarization of the $3d$ states of second-neighbor Ga's. For Zn, the $3d$ states are even shallower, and they mix into the impurity state. This may be the cause of the larger Zn binding energy in GaN as compared to e.g. GaAs. In the latter, the delocalized carrier bound to the shallow center sees the Ga and Zn cores as effectively identical: this may not hold in GaN, where the $3d$'s hybridize with sp valence states.

Finally, whether or not acceptors in GaN behave effective-mass like is an open issue. It may be speculated that the answer is in the affirmative: using an average hole mass $\overline{m}_h \sim 0.8 m_e$ the hydrogenic binding energy is 0.4 eV (not far from the “isocoric” acceptor Zn) when the high-frequency dielectric constant $\varepsilon \equiv \varepsilon_\infty = 5.4$ is used. This is suggested by the fact that most acceptor binding energies are much larger than typical GaN phonon energies.¹⁰ As for the shallower Be center, Be is expected to have repulsive central cell corrections, and its smaller binding energy may imply using a low-frequency dielectric constant $\varepsilon \equiv \varepsilon_0 \sim 10$ instead: in this case the binding energy is in fact ~ 0.1 eV. Of course the valence band structure and wave-vector-dependent screening must be described in detail before any conclusion can be reached.

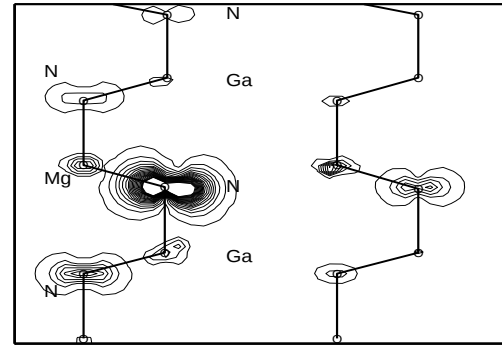


Fig. 2: Number density of the impurity state for Mg. Note the p_{xy} -like character and the localization on the first-neighbor shell.

4. References

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